



Form PTO-1449 (modified)

Atty. Docket No.

2000.106500/DE0260

Serial No.

10/602,192

List of Patents and Publications for Applicant's

Applicant

Markus Nopper and Axel Preusse

## INFORMATION DISCLOSURE STATEMENT

(Use several sheets if necessary)

Filing Date:

June 24, 2003

Group:

2811

2825

U.S. Patent Documents

See Page 1

Foreign Patent Documents

See Page 1

Other Art

See Page 1

## U.S. Patent Documents

Exam. Init.	Ref. Des.	Document Number	Date	Name	Class	Sub Class	Filing Date of App.
CME	A1	2002/0050459 A1	5/02/02	Matsuda <i>et al.</i>	205	118	—
CME	A2	6,479,902 B1	11/12/02	Lopatin <i>et al.</i>	257	774	—
	A3						
	A4						
	A5						

## Foreign Patent Documents

Exam. Init.	Ref. Des.	Document Number	Date	Country	Class	Sub Class	Translation Yes/No
CME	B1	EP 1 201 787 A2	5/02/02	Europe	C23C	18/28	Yes
CME	B2	WO 02/45155 A2	6/06/02	PCT	H01L	21/768	Yes
CME	B3	2002356733 A	12/13/02	Japan	C22C	27/04	Yes

## Other Art (Including Author, Title, Date Pertinent Pages, Etc.)

Exam. Init.	Ref. Des.	Citation
CME	C1	Shacham-Diamand <i>et al.</i> , "Electroless copper deposition for ULSI," <i>Thin Solid Films</i> , 262:93-103, 1995
CME	C2	Lin <i>et al.</i> , "Interfacial mechanism studies of electroless plated CU films on $\alpha$ -Ta:N layers catalyzed by PIII," <i>J. Vac. Sci. Technol.</i> , 20:733-40, 2002
	C3	

EXAMINER:

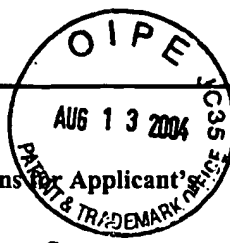
C. Ruerker

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~~2011~~ 2826

 U.S. Patent Documents  
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 Foreign Patent Documents  
See Page 1

 Other Art  
See Page 1

## U.S. Patent Documents

Exam. Init.	Ref. Des.	Document Number	Date	Name	Class	Sub Class	Filing Date of App.
CME	A3	5,969,422	10/19/99	Ting <i>et al.</i>	257	762	—
CME	A4	6,461,675 B2	10/08/02	Paranjpe <i>et al.</i>	427	250	—
	A5						
	A6						
	A7						

## Foreign Patent Documents

Exam. Init.	Ref. Des.	Document Number	Date	Country	Class	Sub Class	Translation Yes/No
	B1						
	B2						
	B3						

## Other Art (Including Author, Title, Date Pertinent Pages, Etc.)

Exam. Init.	Ref. Des.	Citation
	C1	
	C2	
	C3	

EXAMINER:

C. Suerhart

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